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MCI, Inc.  
1133 19th Street, NW  
Washington, DC 20036

In re Application of : NOTICE OF WITHDRAWAL  
B. Reilly Barry, et.al. : FROM ISSUE  
Application No: 09/159,503 UNDER 37 CFR 1.313(b)  
Filed: September 24, 1998  
Attorney Docket No.: COS-97-101

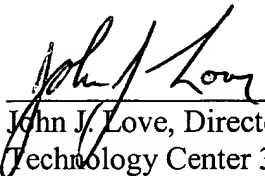
The above-identified application is withdrawn from issue due for consideration of the Request for Continued Examination (RCE) on August 15, 2005. See 37 CFR 1.313(b).

The above-identified application is hereby withdrawn from issue.

The issue fee and publication fee are refundable upon written request. Applicant may also request that the fee be credited to a specified Deposit Account. Applicant may, however, wait until such time as the application is either allowed or abandoned to make such request. If the application is subsequently allowed, upon receipt of a new Notice of Allowance and Issue and Publication Fee Due, applicant may further request that the previously submitted issue fee and publication fee be applied toward payment of the issue fee and publication fee in the amount identified in the new Notice of Allowance and Issue and Publication Fee Due. This request, and any balance due, must be received on or before the due date noted in the new Notice of Allowance and Issue and Publication Fee Due in order to prevent abandonment of the application. If the application is abandoned, applicant may request either a refund or a credit to a specified Deposit Account.

Telephone inquiries should be directed to Supervisory Patent Examiner James Trammell at (571)-272-6712.

The above-identified application is being forwarded to the examiner for prompt appropriate action, including notifying applicant of the new status of this application.

  
John J. Love, Director  
Technology Center 3600

cc: Office of Patent Publication